Patent Abstracts of Japan

PUBLICATION NUMBER

05214298

PUBLICATION DATE

24-08-93

APPLICATION DATE

07-02-92

APPLICATION NUMBER

04056055

APPLICANT: NIPPON CARBIDE IND CO INC;

INVENTOR: MARUYAMA MASATOSHI;

INT.CL.

: C09J 4/00

TITLE

: PRESSURE-SENSITIVE ADHESIVE COMPOSITION CURABLE BY ACTINIC

RADIATION

ABSTRACT: PURPOSE: To provide the title composition which can form a pressure-sensitive adhesive layer excellent both in the pressure-sensitive adhesiveness and the initial adhesive power before irradiation with actinic radiation and in the rubber elasticity, the extensibility and the reduction in adhesive power after the irradiation and which is suitable particularly for the dicing of semiconductor wafer.

> CONSTITUTION: The title composition contains a (co)polymer (A) capable of forming a pressure-sensitive adhesive layer, one or more compounds (B) having at least one vinyl ether group in the molecule, and one or more compounds (C) having at least two radical-polymerizable unsaturated groups in the molecule and other than the compounds B, wherein the total of the compounds B and C is 20-600 pts.wt. based on 100 pts.wt. compound A and the compound B accounts for 5-50wt.% of the total of the compounds B and C.

COPYRIGHT: (C)1993,JPO&Japio

copolymer (A)